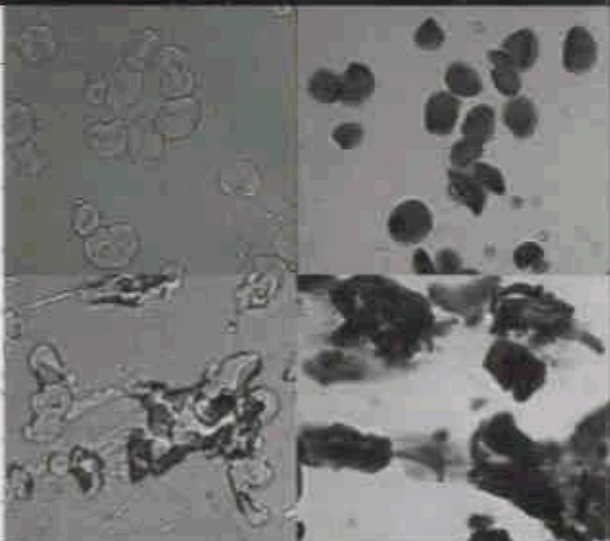
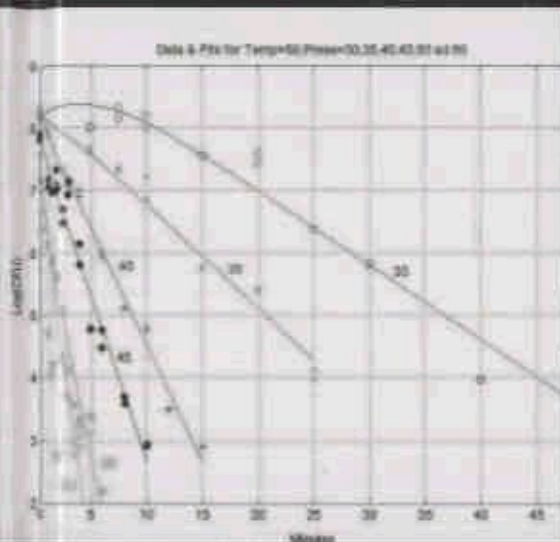


# High Pressure Processing of Foods




**EDITORS**

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Foreword contributed by C. Patrick Dunne

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# CONTENTS

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Contributors	ix
Foreword	xv
Prologue	xix
Preface	xxi
Acknowledgments	xxv
<b>Chapter 1.</b> Introduction to High Pressure Processing of Foods	1
<i>Margaret F. Patterson, Mark Linton, and Christopher J. Doona</i>	
<b>Chapter 2.</b> Germination of Spores of <i>Bacillus subtilis</i> by High Pressure	15
<i>Peter Setlow</i>	
<b>Chapter 3.</b> Inactivation of <i>Bacillus cereus</i> by High Hydrostatic Pressure	41
<i>Murad A. Al-Holy, Mengshi Lin, and Barbara A. Rasco</i>	
<b>Chapter 4.</b> Inactivation of <i>Bacillus</i> Spores at Low pH and in Milk by High Pressure at Moderate Temperature	69
<i>Isabelle Van Opstal, Abram Aertsen, and Chris W. Michiels</i>	
<b>Chapter 5.</b> Pressure and Heat Resistance of <i>Clostridium botulinum</i> and Other Endospores	95
<i>Michael G. Gänzle, Dirk Margosch, Roman Buckow, Matthias A. Ehrmann, Volker Heinz, and Rudi F. Vogel</i>	

<b>Chapter 6.</b>	The Quasi-chemical and Weibull Distribution Models of Nonlinear Inactivation Kinetics of <i>Escherichia coli</i> ATCC 11229 by High Pressure Processing <i>Christopher J. Doona, Florence E. Feeherry, Edward W. Ross, Maria Corradini, and Micha Peleg</i>	115
<b>Chapter 7.</b>	Sensitization of Microorganisms to High Pressure Processing by Phenolic Compounds <i>Yoon-Kyung Chung, Aaron S. Malone, and Ahmed E. Yousef</i>	145
<b>Chapter 8.</b>	Functional Genomics for Optimal Microbiological Stability of Processed Food Products <i>Stanley Brul, Hans van der Spek, Bart J.F. Keijser, Frank H.J. Schuren, Suus J.C.M. Oomes, and Roy C. Montijn</i>	173
<b>Chapter 9.</b>	Determination of Quality Differences in Low-Acid Foods Sterilized by High Pressure versus Retorting <i>Ming H. Lau and Evan J. Turek</i>	195
<b>Chapter 10.</b>	Consumer Evaluations of High Pressure Processed Foods <i>Alan O. Wright, Armand V. Cardello, and Rick Bell</i>	219
<b>Chapter 11.</b>	Compression Heating and Temperature Control in High Pressure Processing <i>Edmund Ting</i>	227
	Index	235